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FILING RECEIPT



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Domestic Priority data as claimed by applicant

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Foreign Applications

REPUBLIC OF KOREA 2000-69660 11/22/2000

If Required, Foreign Filing License Granted: 10/22/2003

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Non-Publication Request: No

Early Publication Request: No

** SMALL ENTITY **

Title

Method of etching semiconductor device using neutral beam and apparatus for etching the same

Preliminary Class